

Monday, September 7, 2020

- 08:30 - 09:00 Registration | Tutorial 1
09:00 - 16:45 **Tutorial 1 | Panorama Saal**
Fundamentals and Trends of Plasma Surface Processing
- 09:00 - 09:30 Registration | Tutorial 2
09:30 - 17:15 **Tutorial 2 | Carl Zeiss Saal**
Pulsed Plasmas and Their Applications
- 09:30 - 10:00 Registration | Tutorial 3
10:00 - 17:00 **Tutorial 3 | Heinrich Erhardt Saal**
Processing on Flexible Glass - Challenges and Opportunities (SVC C-341)
- 13:00 - 15:00 Registration for Exhibitors | Entrance East / Eingang Ost
13:00 - 17:00 Booth Construction for Exhibitors | Foyer Halle 1

Welcome Afternoon | Entrance East / Eingang Ost

- 15:00 - 15:45 Registration | Event A
15:45 - 16:30 Registration | Event B
16:30 - 17:15 Registration | Event C

- 17:20 - 18:15 Rudolf-Jaeckel-Preis | Carl Zeiss Saal**
Award Ceremony with Award Winners Lecture
Outstanding scientist from the field of vacuum
technology presented by Deutsche
Vakuum-Gesellschaft DVG e.V.

"Development of Ultrawide-Gap Semiconductors and Demonstration of Devices"

Prof. Dr. Marius Grundmann, Leiter der Halbleiterphysik,
Felix-Bloch-Institut für Festkörperphysik, Universität Leipzig, Germany

- 18:15 - 20:00 Welcome Evening with Thuringian Fried Sausage & Beer | Halle 1 & Foyer Halle 1**